

**Title of Abstract Here**  
**(Times New Roman, 14 pt, bold, centered)**

First name LAST NAME,<sup>1</sup> First name LAST NAME,<sup>2</sup> First name LAST NAME \*,<sup>2</sup>  
(Presenting author underlined, \* refers to the corresponding author, Times New Roman, 11 pt, normal, centered)

<sup>1</sup>*Affiliation 1, City, Country;*  
<sup>2</sup>*Affiliation 2, City, Country*  
(Times New Roman, 11 pt, italic, centered)

Keywords:

(3-5 keywords, Times New Roman, 12 pt)

Guidelines:

- (1) The abstract must be written in English.
- (2) The abstract should not exceed **one page** of Letter format (8.5" × 11") in portrait layout with all margins equal to 1".
- (3) The single-spaced text should be typed in normal Times New Roman font being left and right justified. Please use 12 pt font size for the main body of text.
- (4) All text, equations, figures, schemes and references (e.g., "[1, 2]" or "[1-3]" after a word or sentence) should be integrated in the one-page abstract. Please do not provide separate graphics files. Figures cannot exceed one third of the abstract page. References should follow the format given below. The number of references cannot exceed five.
- (5) The abstract should be submitted as an MS Word file (.doc or .docx).

**Fig. 1: short legend to figure**  
**(Times New Roman, 11 pt, bold, centered)**

[1] Jeong, C.; Choi, C.-H. Single-Step Direct Fabrication of Pillar-on-Pore Hybrid Nanostructures in Anodizing Aluminum for Superior Superhydrophobic Efficiency. *ACS Appl. Mater. Interfaces* **2012**, *4*, 842-848.

[2] Liu, Y.; Du, K.; Wathuthanthri, I.; Xu, W.; Choi, C.-H. 3-D Nanofabrication using Nanostructured Photoresist Film as Free-Standing Appliqué. In *International Conference on Micro Electro Mechanical Systems*; Paris, 2012.

(Times New Roman, 11 pt, justified)